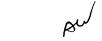


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APPLICATION NO.	FILING I	DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO		
10/084,761	02/20/2002		Hiroshi Sawada	JCLA8894	3473		
75	590	12/24/2003		EXAMINER			
J.C. Patents Suite 250				ESTRADA,	ESTRADA, MICHELLE		
4 Venture				ART UNIT	PAPER NUMBER		
Irvine, CA 92	618			2823			
				DATE MAILED: 12/24/200	1		

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.		Applicant(s)					
	10/084,761	,761 SAWADA, HIROSHI		HI				
Office Action Summary	Examiner		Art Unit	0.				
	Michelle Es		2823	<i>49</i> 60				
The MAILING DATE of this communication ap Period for Reply	ppears on the c	over sheet with the c	orrespondence ad	dress				
• •	LVIC CET TO	EVDIDE 2 MONTH/	C) EDOM					
A SHORTENED STATUTORY PERIOD FOR REPITHE MAILING DATE OF THIS COMMUNICATION - Extensions of time may be available under the provisions of 37 CFR 1 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a re - If NO period for reply is specified above, the maximum statutory period - Failure to reply within the set or extended period for reply will, by statu - Any reply received by the Office later than three months after the mailie earned patent term adjustment. See 37 CFR 1.704(b).	1.136(a). In no event pply within the statuto d will apply and will e tte, cause the applica	, however, may a reply be tim ry minimum of thirty (30) days expire SIX (6) MONTHS from ation to become ABANDONEI	nely filed s will be considered timel the mailing date of this co O (35 U.S.C. § 133).	y. ommunication.				
Status 								
1) Responsive to communication(s) filed on 14 or								
2a)⊠ This action is FINAL . 2b)☐ This	s action is non	-final.						
Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under Ex parts Quayle, 1935 C.D. 11, 453 O.G. 213.								
Disposition of Claims								
4) Claim(s) 1,3,7 and 9-20 is/are pending in the	application.							
4a) Of the above claim(s) is/are withdra	awn from cons	ideration.						
5) Claim(s) is/are allowed.								
6)⊠ Claim(s) <u>1,3,7 and 9-20</u> is/are rejected.								
7) Claim(s) is/are objected to.								
8) Claim(s) are subject to restriction and/	or election req	uirement.						
Application Papers								
9)☐ The specification is objected to by the Examir	ner.							
10)☐ The drawing(s) filed on is/are: a)☐ ac								
Applicant may not request that any objection to the								
Replacement drawing sheet(s) including the corre	•			• •				
11) The oath or declaration is objected to by the E	=xaminer. Note	the attached Office	Action or form P	O-152.				
Priority under 35 U.S.C. §§ 119 and 120								
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 13) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. § 119(e) (to a provisional application) since a specific reference was included in the first sentence of the specification or in an Application Data Sheet. 37 CFR 1.78. a) The translation of the foreign language provisional application has been received. 14) Acknowledgment is made of a claim for domestic priority under 35 U.S.C. §§ 120 and/or 121 since a specific reference was included in the first sentence of the specification or in an Application Data Sheet. 37 CFR 1.78. 								
Attachment(s)								
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(s)	5)						

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DETAILED ACTION

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1, 3, 7, 9-11, 14, 15, 17 and 18 are rejected under 35 U.S.C. 103(a) as being unpatentable over the combination of Harris et al. (3,824,678) and Haight et al. (6,333,485).

Harris et al. disclose irradiating a substrate with pulse laser to cut it (Col. 2, lines 58-60); the surface of the substrate is irradiated with the laser; the substrate is a semiconductor substrate formed with a number of elements and said pulse laser is irradiated along the scribed lines between said elements (Col. 6, lines 59-60). Harris et al. discloses that the back of the semiconductor wafer is drawn by an x-y table (Col. 6, lines 19-25); the laser is irradiated to the semiconductor wafer excluding the peripheral portion.

Harris et al. does not disclose the specific pulse width of the laser.

Haight et al. disclose cutting and removing material from a sample by a laser operating in pulse widths to the picosecond (Col. 2, lines 22-23).

It would have been within the scope of one of ordinary skill in the art to combine the teachings of Harris et al. and Haight et al. to achieve the cutting step of the substrate.

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Alternatively, choice of a particular pulse width would have been a matter of routine experimentation within the teachings of the references.

Harris et al. discloses the claimed invention except for the pulse width of the laser. It would have been obvious to one having ordinary skill in the art at the time the invention was made to use the pulse width of one or less than one picoseconds, since it has been held that where the general conditions of a claim are disclosed in the prior art, discovering the optimum or workable ranges involves only routine skill in the art. *In re Aller*, 105 USPQ 233.

In addition, the selection of the pulse width, its obvious because it is a matter of determining optimum process conditions by routine experimentation with a limited number of species of result effective variables. These claims are prima facie obvious without showing that the claimed ranges achieve unexpected results relative to the prior art range. In re Woodruff, 16 USPQ2d 1935, 1937 (Fed. Cir. 1990). See also In re Huang, 40 USPQ2d 1685, 1688 (Fed. Cir. 1996)(claimed ranges or a result effective variable, which do not overlap the prior art ranges, are unpatentable unless they produce a new and unexpected result which is different in kind and not merely in degree from the results of the prior art). See also In re Boesch, 205 USPQ 215 (CCPA) (discovery of optimum value of result effective variable in known process is ordinarily within skill or art) and In re Aller, 105 USPQ 233 (CCPA 1995) (selection of optimum ranges within prior art general conditions is obvious).

Note that the specification contains no disclosure of either the critical nature of the claimed pulse width or any unexpected results arising therefrom.

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Where patentability is said to be based upon particular chosen pulse width or upon another variable recited in a claim, the Applicant must show that the chosen pulse width is critical. *In re Woodruf*, 919 F.2d 1575, 1578, 16 USPQ2d 1934, 1936 (Fed. Cir. 1990).

Choice of a particular thickness of the semiconductor wafer would have been considered a matter of routine optimization. See MPEP 2144.05.

Claims 12, 13, 16, 19 and 20 are rejected under 35 U.S.C. 103(a) as being unpatentable over Harris et al. in combination with Haight et al. as applied to claims 1, 3, 7, 9-11, 14, 15, 17 and 18 above, and further in view of Usami (6,440,773).

The combination of Harris et al. and Haight et al. does not disclose that the semiconductor wafer has a batch-processed adhesive agent layer on the back.

Usami discloses applying an adhesive to the back of the substrate (4907) and cutting the wafer with a laser (Claim 3).

It would have been within the scope of one of ordinary skill in the art to combine the teachings of Harris et al., Haight and Usami to enable formation of the wafer and further the adhesive provides protection to the substrate in subsequent steps.

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Response to Arguments

Applicant alleges that the pulse separation time of 3-30 ps has achieved unexpected results. However, the applicant has merely recognized properties of the process made obvious by the combination. Furthermore, applicant does not point to objective evidence establishing unexpected results.

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Michelle Estrada whose telephone number is (703) 308-0729 or (571) 272-1858. The examiner can normally be reached on Monday through Friday.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Olik Chaudhuri can be reached on 703-306-2794 or 571-272-1855. The fax phone numbers for the organization where this application or proceeding is assigned are 703-308-7722 for regular communications and 703-308-7724 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0956.

George Fourson Primary Examiner Art Unit 2823

MEstrada

December 17, 2003